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Docket No.: T0203.0008/P008
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Seitaro Matsuo et al.

Application No.: 10/510,479

Confirmation No.: 7443

Filed: October 8, 2004

Art Unit: 1763

For: ECR PLASMA SOURCE AND ECR
PLASMA DEVICE

Examiner: R. K. Dhingra

AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

INTRODUCTORY COMMENTS

In response to the Office Action dated July 14, 2006, please amend the above-identified U.S. patent application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 6 of this paper.